

Supporting Materials

Type-III Organic/Two-Dimensional multi-layer Phototransistors with Promoted Operation Speed at Communication Band

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1. The EDS of graphene/HAT-CN/Bi₂O₂Se on SiO₂ substrate.

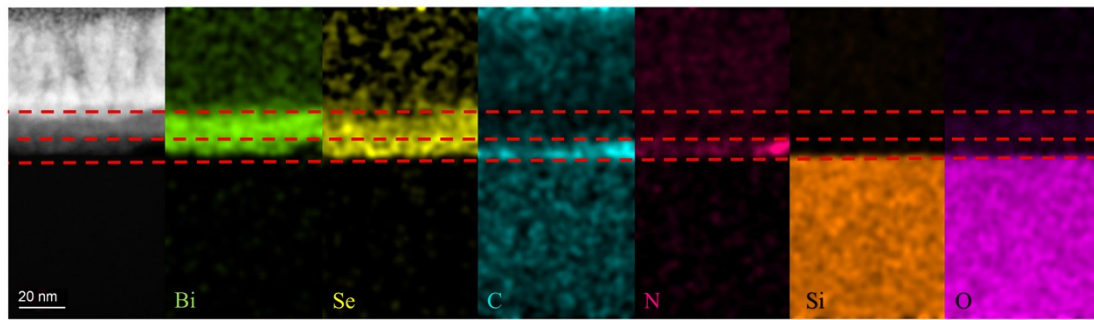


Fig. S1. The EDS of our device can distinguish Bi₂O₂Se and graphene/HAT-CN.

2. The Raman spectrum of HAT-CN on SiO₂ substrate.

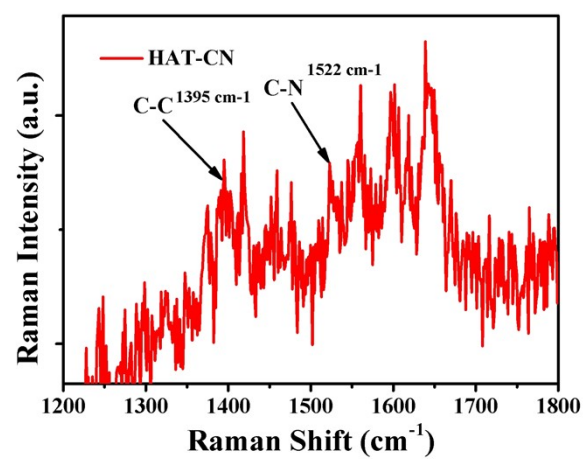


Fig. S2. The Raman spectrum of HAT-CN can distinguish C-C peak and C-N peak.

3. The V_g modulation on graphene/HAT-CN/ $\text{Bi}_2\text{O}_2\text{Se}$ phototransistor.

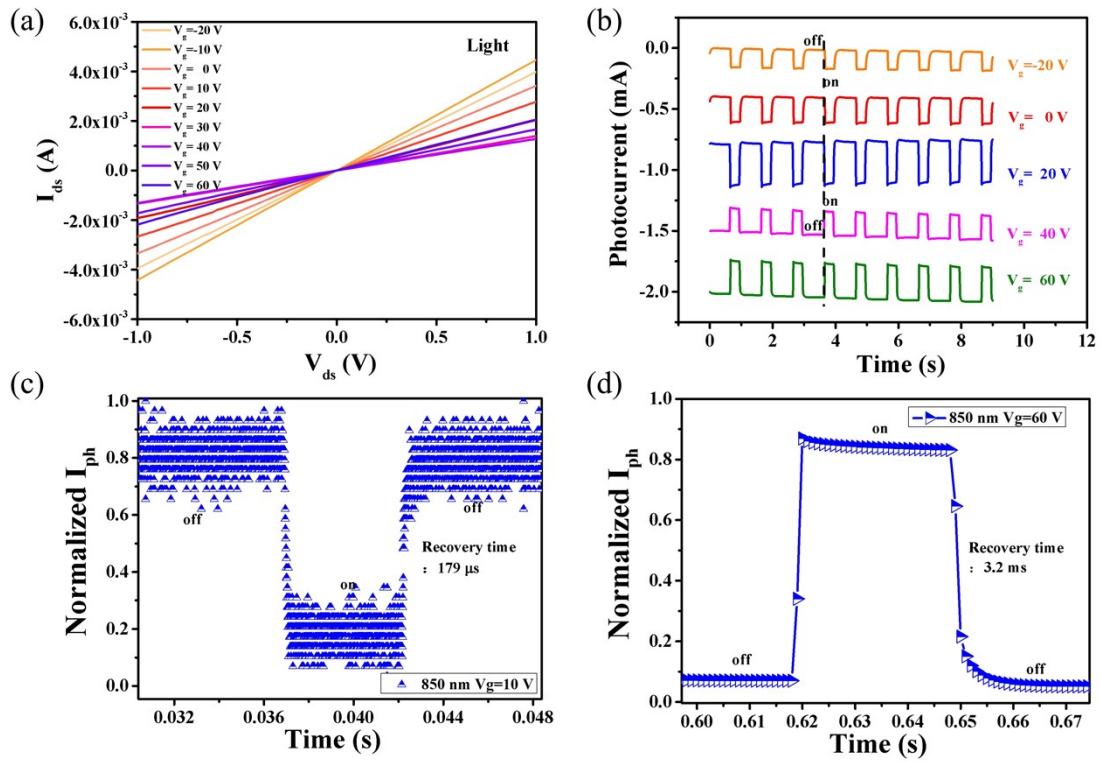


Fig. S3. The IV and photocurrent measurements at different gate voltages under the 850 nm with 60 mW/cm^2

4. The graphene/Bi₂O₂Se control phototransistor.

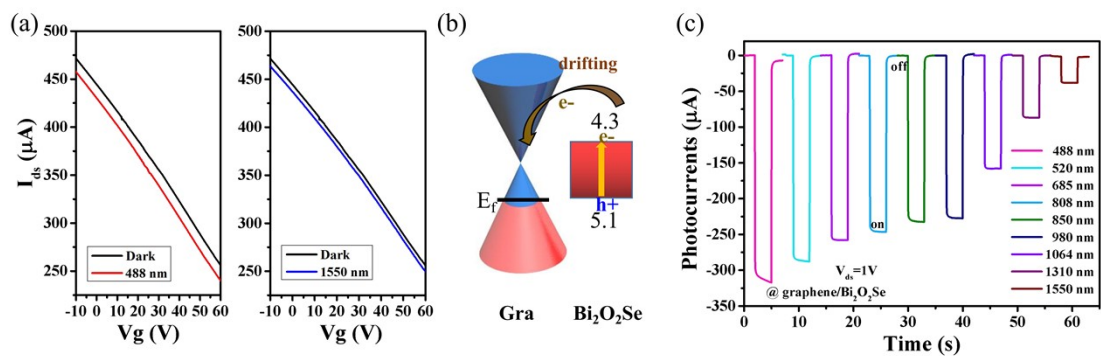


Fig. S4. Optoelectronic characterization and measurements of graphene/Bi₂O₂Se phototransistor. (a) The V_{ds} curve with varied V_g applying. (b) The energy band schematic of graphene/Bi₂O₂Se. (c) Transient response performance of graphene/Bi₂O₂Se.

5. Photocurrent measurements at increasing input power density.

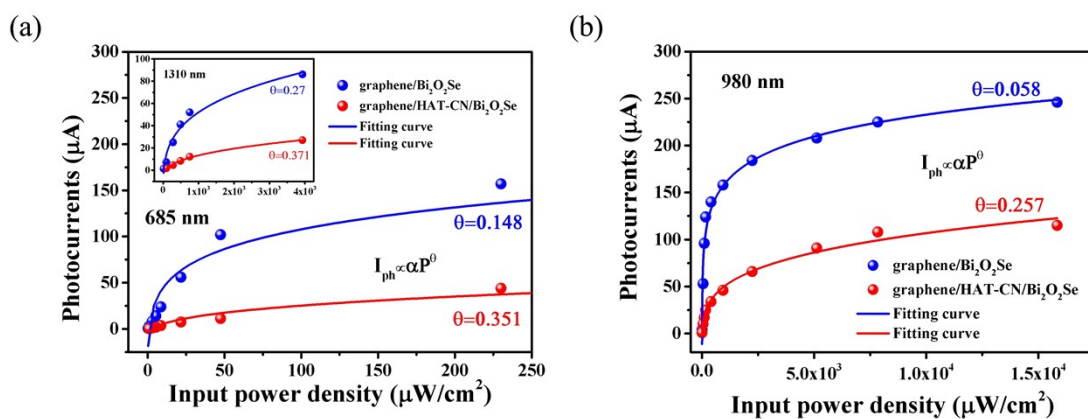


Fig. S5. Transient photocurrent measurements at increasing input power density of graphene/Bi₂O₂Se and graphene/HAT-CN/Bi₂O₂Se control devices.

6. The response time of graphene/HAT-CN/Bi₂O₂Se at communication band.

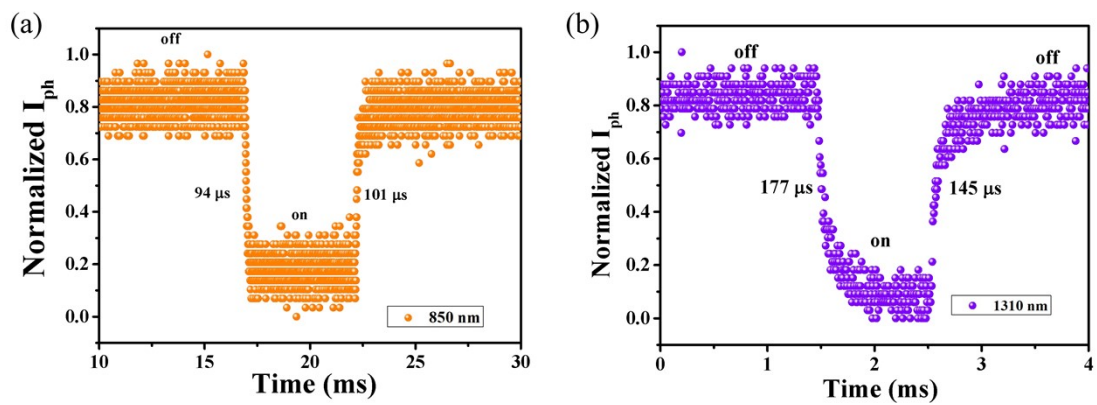


Fig. S6. (a,b) The dynamic response time of graphene/HAT-CN/Bi₂O₂Se with the irradiated light at 850 and 1310 nm.

7. The thickness dependent performance of graphene/HAT-CN/Bi₂O₂Se.

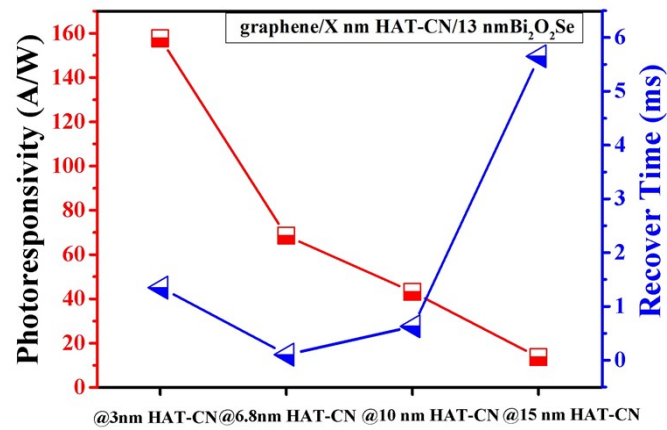


Fig. S7. The responsivity and recover time of thickness various HATCN devices at 1310 nm.

8. The noise spectrum of graphene/Bi₂O₂Se

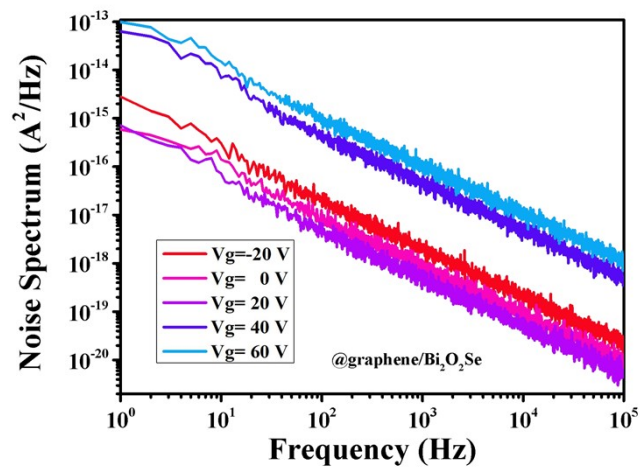


Fig. S8. The 1/f noise analysis of the device for different V_g values.

9. The stability of graphene/HAT-CN/Bi₂O₂Se

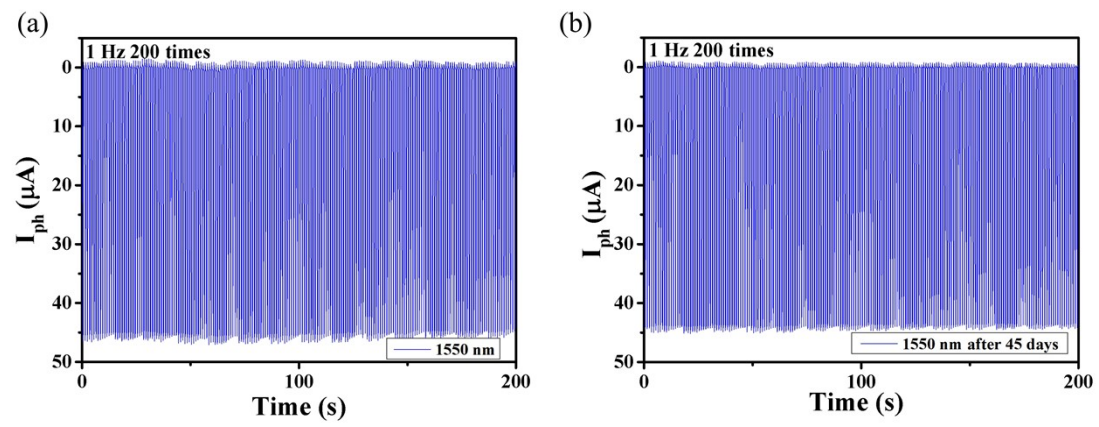


Fig. S9. (a) The detection stability of graphene/HAT-CN/Bi₂O₂Se at 1550 nm. (b) And after 45 days, the stability of graphene/HAT-CN/Bi₂O₂Se.